

L Number	Hits	Search Text	DB	Time stamp
1	25415	(TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 10:49
2	380	((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and (((angstrom nanometer micron micrometer) adj2 (second s minute min)) ?ang./min ?ang./minute "nm/min" "nanometer/min" "nm/minute" "nanometer/minute" ?mu./min ?mu./minute "micrometer/min" "micrometer/minute")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:00
3	0	?ang./min	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 10:57
5	756	((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:08
6	335	((((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @ad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:08
7	206	((((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @rlad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:08
8	415	(((((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @ad<19981215) (((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @rlad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:08
9	66	((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) same ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:15

10	26	(((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) same ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))) and @ad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:17
11	9	(((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) same ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))) and @rlad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:09
12	32	(((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) same ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))) and @ad<19981215 (((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) same ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))) and @rlad<19981215)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:09
13	4123	(deposit\$3 near3 rate) near15 ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:17
14	156	((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((deposit\$3 near3 rate) near15 ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:17
15	92	(((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((deposit\$3 near3 rate) near15 ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @ad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:17
16	62	(((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((deposit\$3 near3 rate) near15 ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @rlad<19981215	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:17

17	116	<p>(((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((deposit\$3 near3 rate) near15 ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @ad<19981215) (((TEOS TMOS siloxane ((organic organo) adj2 (silicon silane)) organosiloxane organosilicon organosiloxane tetraethylorthosilicate tetraethoxysilane alkoxysilane) same (water "H.sub.2O" "H.sub.2 O" peroxide or H2O2 or "H.sub.2O.sub.2" "H.sub.2 O.sub.2")) and ((deposit\$3 near3 rate) near15 ((angstrom ang nanometer nm micron mu micrometer) adj2 (second s minute min)))) and @rlad<19981215)</p>	<p>USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB</p>	2004/04/16 11:17
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